

## TDR Review Committee meeting

### *Plasma section* 30<sup>th</sup> November-2<sup>nd</sup> December 2022

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#### 2.8 Plasma Section

Very good progress was made with the plasma source for the ~500MeV energy gain. An ~40 cm capillary discharge now operates at the plasma laboratory. It is similar to the ~3 cm discharge, also occurring in a 3D-printed capillary, but with six gas inputs, instead of two. It produces a plasma with density varying. longitudinally between ~1.5 and  $3\times1017$  cm-3. Surprisingly, the plasma density variation is comparable to that observed with the 3-cm-long capillary and also occurs over the entire half length of the discharge. The hypothesis is that the variation in plasma density over the length of the discharge can be compensated by varying the diameter of the discharge tube.

Vacuum measurements show that operating at 100 Hz requires an almost continuous gas flow. Operating at 400 Hz requires a continuous flow, posing a challenge for maintaining good vacuum before and after the plasma source.

Measurements also show that the density of the discharge in a 3D-printed capillary decreases as a function of the number of discharges, e.g., 30% over one hundred thousand events. On the contrary, it remains constant over that number of discharges in a sapphire capillary. A cheaper, 3D-printed glass capillary may offer the same lifetime as a sapphire capillary.

A plasma length allowing for 5 GeV energy gain, longer but also with a larger transformer ratio acceleration maybe possible by stacking three 40-cm-long discharges.

The use of a laser pulse to decrease time jitter of the discharge with respect to the electrical trigger and reduce variations of plasma density from event to event was presented at previous meetings. Is this method applicable to the longer discharge and will it be implemented (if needed)?

<u>The RC recommends that capillaries with tapered radius to compensate for the (non constant) longitudinal plasma density profile measured in the constant-radius capillaries be tested very soon. This test can be done with the short capillary.</u> For consistency, requirements in terms of uniformity of the longitudinal plasma density should be determined from simulation studies. Alternatively, numerical simulations may be performed to determine the effect of the observed non-uniformity on the beam and FEL parameters. Density ramps at the plasma entrance and exit of the capillary should also be carefully characterized and included in numerical simulations.







#### Plasma module for EuPraxia project

- 1.1 GeV (1.5 GV/m 40cm capillary density 10<sup>16</sup> cm-3)
  - Direct plasma discharge for 40cm long capillary
    - Stability
    - Longitudinal profiles
  - Plasma sources operating at 100 400 Hz
    - Vacuum system
    - Study on materal science to increase capillary's longevity
    - High-voltage sources for plasma formation
- Segmented capillary (
  - Plasma sources larger than 40 cm (m-scale)
  - Longitudinal density modulation
  - 5 GeV case for EuPRAXIA (1.5 GV/m m-scale capillary density 10<sup>16</sup> cm-3)







Plasma module developments: channel shaping



#### Presented in the previous RC 26 - 27th October 2021





#### Plasma module developments: channel shaping





*30<sup>th</sup> November – 2<sup>nd</sup> December 2022* 

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Plasma section developments: erosion of walls capillary



Mitigation of erosion of the capillary walls can be achieved by reducing the heat flux



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Plasma section developments: erosion of walls capillary





Stronger materials as sapphire or Glass can support a larger number of shots at 1 Hz but higher repetition rates produce a deformation of the channel that in turn changes the longitudinal density profile





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EUPRAXIA

 $T_{\rm e}({\rm eV}) = 5.7 \left[ \frac{I({\rm kA})}{r_{\rm cap}({\rm mm})} \right]^{2/5}$ 

1Hz repetition rate

The larger is the current density, the stronger is the damaging of the plasma channel, because the thermal energy to be dissipated by the capillary walls will increase



#### Plasma section developments: erosion of walls capillary





The damaging of the capillary depends on the plasma current density and also on the repetition rate of the discharge, since the higher is the repetition frequency the larger is the thermal energy accumulated on the capillary walls







#### Glass 3D printer





3cmx0.5mm capillary Ip = 300 A

3cmx1mm capillary lp = 300 A

3cmx2mm capillary lp = 300 A

- 3cmx0.5 mm and 3cmx1mm show a strong deformation but no blackened parts
- Sapphire and glass materials do not show a deformation along the longitudinal coordinate like the plastic capillary composed of plastic but have a blackened parts on the positive electrode
- Also the 3cmx2mm channel does not show a strong deformation but it is completely blackened



#### Plasma section developments: high voltage source for plasma formation





In priciple, the HV pulser is able to support 400 Hz RepRate, heating issues can limit the RepRate, but the primary electric source could represent a limit to operate at High rep rate:

 $Q=CV=10kV \times 40nF = 0.4\times 10^{-3} C$  $t_c = dQ/I_c = 20 ms per pulse (with I_c=20 mA)$ Max Rep rate 50 Hz with the current HV ger

|         |                                 |  |   |  | LECBOY   |
|---------|---------------------------------|--|---|--|--|
|         | RepRate<br>(Hz)                 | 40cmx2mm (10kV)<br>(EuPRAXIA plasma<br>source) | 3cmx2mm<br>(5kV)(Current<br>plasma<br>source) |  | VC   |
|         | Current HV<br>gen 35kV-<br>20mA | 50 Hz  | 100 Hz  | tc=20ms  |  |
| )<br>en | New HV gen<br>25kV-<br>200mA    | 500 Hz<br>tc = 2 ms                            | 1 kHz<br>tc = 1 ms                            | CHI=1.000<br>CHI=2.000<br>CH4=2.000<br>CH4=2.000 | G = 29,3542<br>M 5.00ms<br>M Pos:0.00ys<br>300 |

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*EuPRAXIA plasma sources: 40cm long capillary* 



#### Presented in the previous RC 6 - 7<sup>th</sup> June 2022



• Rep rate at 1 Hz

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- 10 kV 380 A minimum values to have the ionization (3 kV 140 A for 3cmx2mm)
- Aperture time E-valve/Voltage delay is 8ms/12 ms (3-4 ms/5-6 ms for 3cmx2mm)
- 6 inlets of 1 mm in diameter separated by 60mm/80mm (1 or 2 inlets for 3cmx2mm)



*EuPRAXIA plasma sources: 40cm long capillary* 

## EUPRAXIA

- Presented in the previous RC 6 7<sup>th</sup> June 2022
- All mirrors and lenses have been mounted on movable breadboards In order to scan the entire lenght of the capillary
- Blind area where there is windwow supports (could be reduced)
- 10<sup>16</sup> 10<sup>17</sup> cm-3 range (EuPRAXIA goal)







#### EuPRAXIA plasma sources: 40cm long capillary







*<sup>30&</sup>lt;sup>th</sup> November – 2<sup>nd</sup> December 2022* 

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#### EuPRAXIA plasma sources: segmented capillary







17

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#### All sections of the Plasma module for EuPraxia project are ongoing

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# Thank you for your attention

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